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⑤ **Low emissivity film for high temperature processing.**

⑦ A multiple-layer, high transmittance, low emissivity coated article which can be subjected to high temperature processing such as bending, annealing, tempering, laminating or glass welding is disclosed, as well as use of such a high-temperature resistant coating in a heatable article for deicing, defrosting and/or defogging a transparency.

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LOW EMISSIVITY FILM FOR HIGH TEMPERATURE PROCESSING

Background of the Invention

The present invention relates generally to the art of cathode sputtering of metal oxide films, and more particularly to the art of magnetic sputtering of multiple layer films of metal and metal oxide.

U.S. Patent No. 4,094,763 to Gillery et al discloses producing transparent, electroconductive articles by cathode sputtering metals such as tin and indium onto refractory substrates such as glass at a temperature above 400°F. in a low pressure atmosphere containing a controlled amount of oxygen.

U.S. Patent No. 4,113,599 to Gillery teaches a cathode sputtering technique for the reactive deposition of indium oxide in which the flow rate of oxygen is adjusted to maintain a constant discharge current while the flow rate of argon is adjusted to maintain a constant pressure in the sputtering chamber.

U.S. Patent No. 4,166,018 to Chapin describes a sputtering apparatus in which a magnetic field is formed adjacent a planar sputtering surface, the field comprising arching lines of flux over a closed loop erosion region on the sputtering surface.

U.S. Patent No. 4,201,169 to Gillery discloses a method for making low resistance indium oxide thin films by first depositing a very thin primer layer of indium oxide at low temperature before heating the substrate to deposit the major thickness of the conductive layer of indium oxide by cathode sputtering at typically high cathode sputtering temperatures.

U.S. Patent No. 4,327,967 to Groth discloses a heat-reflecting panel having a neutral-color outer appearance comprising a glass plane, an interference film having a refractive index greater than 2 on the glass surface, a heat reflecting gold film over the interference film and a neutralization film of chromium, iron, nickel, titanium or alloys thereof over the gold film.

U.S. Patent No. 4,349,425 to Miyake et al discloses d-c reactive sputtering of cadmium-tin alloys in argon-oxygen mixtures to form cadmium-tin oxide films having low electrical resistivity and high optical transparency.

U.S. Patent No. 4,462,883 to Harat discloses a low emissivity coating produced by cathode sputtering a layer of silver, a small amount of metal other than silver, and an anti-reflection layer of metal oxide onto a transparent substrate such as glass. The anti-reflection layer may be tin oxide, titanium oxide, zinc oxide, indium oxide, bismuth oxide or zirconium oxide.

In the interest of improving the energy efficiency of double-glazed window units, it is desirable to provide a coating on one of the glass surfaces which increases the insulating capability of the unit by reducing radiative heat transfer. The coating therefore must have a low emissivity in the infrared wavelength range of the radiation spectrum. For practical reasons, the coating must have a high transmittance in the visible wavelength range. For aesthetic reasons, the coating should have a low luminous reflectance and preferably be essentially colorless.

High transmittance, low emissivity coatings as described above generally comprise a thin metallic layer, for infrared reflectance and low emissivity, sandwiched between dielectric layers of metal oxides to reduce the visible reflectance. These multiple layer films are typically produced by cathode sputtering, especially magnetron sputtering. The metallic layer may be gold or copper, but is generally silver. The metal oxide layers described in the prior art include tin oxide, indium oxide, titanium oxide, bismuth oxide, zinc oxide, zirconium oxide and lead oxide. In some cases, these oxides incorporate small amounts of other metals, such as manganese in bismuth oxide, indium in tin oxide and vice versa, to overcome certain disadvantages such as poor durability or marginal emissivity. However, all of these metal oxides have some deficiency.

Although the coating may be maintained on an interior surface of a double-glazed window unit in use, where it is protected from the elements and environmental agents which would cause its deterioration, a durable effective coating able to withstand handling, packaging, washing and other fabrication processes encountered between manufacture and installation is particularly desirable. These properties are sought in the metal oxide. However, in addition to hardness which provides mechanical durability, inertness which provides chemical durability, and good adhesion to both the glass and the metal layer, the metal oxide should have the following properties as well.

The metal oxide must have a reasonably high refractive index, preferably greater than 2.0, to reduce the reflection of the metallic layer and thus enhance the transmittance of the coated product. The metal oxide must also have minimal absorption to maximize the transmittance of the coated product. For commercial reasons, the metal oxide should be reasonably priced, have a relatively fast deposition rate by magnetron sputtering, and be nontoxic.

Perhaps the most important, and most difficult to satisfy, requirements of the metal oxide film

relate to its interaction with the metallic film. The metal oxide film must have low porosity, to protect the underlying metallic film from external agents, and low diffusivity for the metal to maintain the integrity of the separate layers. Finally, and above all, the metal oxide must provide a good nucleation surface for the deposition of the metallic layer, so that a continuous metallic film can be deposited with minimum resistance and maximum transmittance. The characteristics of continuous and discontinuous silver films are described in U.S. Patent No. 4,462,884 to Gillery et al the disclosure of which is incorporated herein by reference.

Of the metal oxide multiple-layer films in general use, those comprising zinc oxide and bismuth oxide are insufficiently durable, those oxides being soluble in both acid and alkaline agents, with the multiple-layer film being degraded by fingerprints, and destroyed in salt, sulfur dioxide and humidity test. Indium oxide, preferably doped with tin, is more durable and protective of an underlying metal layer; however, indium sputters slowly and is relatively expensive. Tin oxide, which may be doped with indium or antimony, is also more durable and protective of an underlying metal layer, but does not provide a suitable surface for nucleation of the silver film, resulting in high resistance and low transmittance. The characteristics of a metal oxide film which result in proper nucleation of a subsequently deposited silver film have not been established; however, trial-and-error experimentation has been widely practiced with the metal oxides described above.

U.S. Patent No. 4,610,771 to Gillery, the disclosure of which is incorporated herein by reference, provides a novel film composition of an oxide of a zinc-tin alloy, as well as a novel multiple-layer film of silver and zinc-tin alloy oxide layers for use as a high transmittance low emissivity coating.

U.S. Application Serial No. 812,680 filed December 123, 1985 by F.H. Gillery discloses improving the durability of multiple layer films, especially multiple layer films comprising antireflective metal and/or metal alloy oxide layers and infrared reflective metal layers such as silver, by providing an exterior protective layer of a particularly chemical resistant material such as titanium oxide.

U.S. Application Serial No. 841,056 filed March 17, 1986 by Gillery et al discloses improving the durability of multiple layer films, especially multiple layer films comprising antireflective metal and/or metal alloy oxide layers and infrared reflective metal layers such as silver, by providing a primer layer such as copper which improves adhesion between the metal and metal oxide layers.

While multiple-layer, low-emissivity, high transmittance films have been made sufficiently durable for architectural applications in multiple glazed win-

dow units, such films have not been sufficiently temperature-resistant to withstand high temperature processing, such as tempering or bending, or to function as heating elements, for example, as deicing, defrosting and/or defogging coatings for windshields.

Summary of the Invention

The present invention involves a novel multiple-layer coating which is sufficiently temperature resistant to enable coated substrates such as glass to be subjected to high temperature processing such as bending, annealing, tempering, laminating or glass welding, or to function as deicing, defrosting and/or defogging elements in a window or windshield. The novel multiple-layer coating of the present invention comprises a first antireflective metal oxide layer such as in oxide of zinc or a zinc-tin alloy, an infrared reflective metal layer such as silver a primer layer containing titanium such as titanium metal or titanium oxide, a second antireflective metal oxide layer and, preferably, an exterior protective layer of titanium metal or titanium oxide.

Detailed Description of the Preferred Embodiments

A film composition preferably comprising an oxide of a metal or metal alloy preferably comprising zinc is preferably deposited by cathode sputtering, preferably magnetron sputtering. A cathode target is prepared comprising the desired metal or metal alloy elements. The target is then sputtered in a reactive atmosphere, preferably containing oxygen in order to deposit a metal or metal alloy oxide film on a surface of a substrate.

A preferred metal alloy oxide in accordance with the present invention is an oxide of an alloy comprising zinc and tin. A zinc tin alloy oxide film may be deposited in accordance with the present invention by cathode sputtering, preferably magnetically enhanced. Cathode sputtering is also a preferred method for depositing high transmittance, low emissivity films in accordance with the present invention. Such films typically comprise multiple layers, preferably a layer of a highly reflective metal such as gold or silver sandwiched between anti-reflective metal oxide layers such as indium oxide or titanium oxide, or preferably an oxide of an alloy of zinc and tin which preferably comprises zinc stannate.

While various metal alloys may be sputtered to form metal alloy oxide films, in order to produce a preferred high transmittance, low emissivity multiple layer film in accordance with the present in-

vention, alloys of tin and zinc are preferred. A particularly preferred alloy comprises zinc and tin, preferably in proportions of 10 to 90 percent zinc and 90 to 10 percent tin. A preferred zinc:tin alloy ranges from 30 to 60 percent zinc, preferably having a zinc:tin ratio from 40:60 to 60:40. A most preferred range is 46:54 to 50:50 by weight tin to zinc. A cathode of zinc:tin alloy reactively sputtered in an oxidizing atmosphere results in the deposition of a metal oxide layer comprising zinc, tin and oxygen, preferably comprising zinc stannate, Zn_2SnO_4 .

In a conventional magnetron sputtering process, a substrate is placed within a coating chamber in facing relation with a cathode having a target surface of the material to be sputtered. Preferred substrates in accordance with the present invention include glass, ceramics and plastics which are not detrimentally affected by the operating conditions of the coating process. More preferred substrates are glass, either clear or tinted. SOLEX® tinted glass is a preferred substrate for vehicle transparencies coated in accordance with the present invention.

The cathode may be of any conventional design, preferably an elongated rectangular design, connected with a source of electrical potential, and preferably employed in combination with a magnetic field to enhance the sputtering process. At least one cathode target surface comprises a metal alloy such as zinc:tin which is sputtered in a reactive atmosphere to form a metal alloy oxide film. The anode is preferably a symmetrically designed and positioned assembly as taught in U.S. Patent No. 4,478,702 to Gillery et al, the disclosure of which is incorporated herein by reference.

In a preferred embodiment of the present invention, a multiple layer film is deposited by cathode sputtering to form a high transmittance, low emissivity coating. In addition to the metal alloy target, at least one other cathode target surface comprises a metal to be sputtered to form a reflective metallic layer. At least one additional cathode target surface comprises the metal to be deposited as the primer layer. A durable multiple layer coating having a reflective metallic film in combination with an anti-reflective metal alloy oxide film is produced as follows, using a primer layer to improve the adhesion between the metal and metal oxide films, which primer layer also provides high-temperature resistance to the multiple-layer coating in accordance with the present invention so that the resultant coated article may be subjected to high temperature processing, such as bending, annealing tempering, laminating, or glass welding without deterioration of the coating. A durable multiple layer coating having a reflective metallic film in combination with an anti-reflective zinc oxide film is

produced using a titanium layer to improve the adhesion between the silver and zinc oxide films, which primer layer also provides high-temperature resistance to the multiple-layer conductive coating in accordance with the present invention so that the resultant coated article may be heated by electrical resistance to produce a deicing, defrosting and/or defogging transparently.

While primer layers of the prior art are preferably of minimal thickness, the primer layer of the present invention is preferably in the range of 10 to 50 Angstroms, most preferably 12 to 30 Angstroms. If a single primer layer is deposited over the reflective metal film, the thickness is preferably greater than 20 Angstroms. If the thickness of the primer layer over the reflective metal layer is less than 20 Angstroms, preferably an additional primer layer is deposited between the first antireflective metal oxide layer and the reflective metal layer.

A clean glass substrate is placed in a coating chamber which is evacuated, preferably to less than 10^{-4} torr, more preferably less than 2×10^{-5} torr. A selected atmosphere of inert and reactive gases, preferably argon and oxygen, is established in the chamber to a pressure between about 5×10^{-4} and 10^{-2} torr. A cathode having a target surface of zinc or zinc:tin metal alloy is operated over the surface of the substrate to be coated. The target metal is sputtered, reacting with the atmosphere in the chamber to deposit a zinc or zinc:tin alloy oxide coating layer on the glass surface.

After the initial layer of zinc or zinc:tin alloy oxide is deposited, the coating chamber is evacuated, and an inert atmosphere such as pure argon is established at a pressure between about 5×10^{-4} and 10^{-2} torr. Preferably, a cathode having a target surface of titanium is sputtered to deposit a first titanium metal primer layer over the zinc:tin alloy oxide layer. In an alternative embodiment, the titanium cathode may be sputtered in a slightly oxidizing atmosphere to deposit a titanium oxide primer layer over the zinc:tin alloy oxide layer. A cathode having a target surface of silver is then sputtered to deposit a reflective layer of metallic silver over the primer layer. A second primer layer is preferably deposited by sputtering titanium over the reflective silver layer. Again, the titanium may be sputtered in an inert atmosphere to deposit a metallic titanium primer layer, or in a slightly oxidizing atmosphere to deposit a titanium oxide primer layer. Finally, a second layer of zinc or zinc:tin alloy oxide is deposited over the second primer layer under essentially the same conditions to deposit the first zinc or zinc:tin alloy oxide layer.

In most preferred embodiments of the present invention, a protective overcoat is deposited over the final metal oxide film. The protective overcoat is preferably deposited by sputtering over the met-

al oxide film a layer of a metal such as disclosed in U.S. Patent No. 4,594,137 to Gillery et al. Preferred metals for the protective overcoat include alloys of iron or nickel, such as stainless steel or Inconel. Titanium is a most preferred overcoat because of its high transmittance. In an alternative embodiment, the protective layer may be a particularly chemical resistant material such as titanium oxide as disclosed in U.S. Serial No. 812,680 filed December 23, 1985 by Gillery et al, the disclosure of which is incorporated herein by reference.

The chemical resistance of a multiple layer film is most improved by depositing a protective coating comprising titanium oxide over the multiple layer film. Preferably, the titanium oxide protective coating is deposited by cathode sputtering at a relatively high deposition rate and low pressure, preferably about 3 millitorr. A protective coating comprising titanium oxide may be formed by sputtering titanium in an oxygen-sufficient atmosphere to deposit titanium oxide directly. In an alternative embodiment of the present invention, a protective coating comprising titanium oxide may be formed by sputtering titanium in an inert atmosphere to deposit a titanium-containing film which subsequently oxidizes to titanium oxide upon exposure to an oxidizing atmosphere such as air.

Similarly, if the primer layers of the present invention are deposited in an inert atmosphere as titanium metal, subsequent high temperature processing results in oxidation of the metal to form titanium oxide.

The present invention will be further understood from the descriptions of specific examples which follow. In Example I, the zinc tin alloy oxide film is referred to as zinc stannate although the film composition need not be precisely Zn_2SnO_4 .

EXAMPLE I

A multiple layer film is deposited on a soda-lime silica glass substrate to produce a high transmittance, low emissivity coated product. A stationary cathode measuring 5 to 17 inches (12.7 by 43.2 centimeters) comprises a sputtering surface of zinc tin alloy consisting of 52.4 weight percent zinc and 47.6 percent tin. A soda-lime-silica glass substrate is placed in the coating chamber which is evacuated to establish a pressure of 4 millitorr in an atmosphere of 50:50 argon-oxygen. The cathode is sputtered in a magnetic field at a power of 1.7 kilowatts while the glass is conveyed past the sputtering surface at a rate of 110 inches (2.8 meters) per minute. A film of zinc stannate is deposited on the glass surface. Three passes produce a film thickness of about 340 Angstroms, resulting in a decrease in transmittance from 90 percent for the

glass substrate to 78 percent for the zinc stannate coated glass substrate. A stationary cathode with a titanium target is then sputtered to produce a titanium primer layer over the zinc stannate, reducing the transmittance to 63 percent. Next, a layer of silver is deposited over the titanium primer layer by sputtering a silver cathode target in an atmosphere of argon gas at a pressure of 4 millitorr. With the substrate passing under the silver cathode target at the same rate, two passes are necessary to deposit ten micrograms of silver per square centimeter, corresponding to a film thickness of about 90 Angstroms, further reducing the transmittance to 44 percent. A second titanium primer layer is sputtered over the silver layer, decreasing the transmittance to a low of 35 percent, and then the second antireflective layer of zinc stannate is deposited, increasing the transmittance to 63 percent.

Finally, a stationary titanium cathode measuring 5 by 17 inches (12.7 by 43.2 centimeters) is sputtered at 10 kilowatts in an atmosphere comprising equal volumes of argon and oxygen at a pressure of 3 millitorr. Two passes of the substrate at a speed of 110 inches (2.8 meters) per minute are sufficient to deposit a protective coating of titanium oxide about 15 to 20 Angstroms thick. The protective coating of titanium oxide does not significantly affect the resistance and reflectance properties of the multiple-layer coating, and changes the transmittance no more than about one percent.

The transmittance of the coated substrate after deposition of all six layers may be as low as 63 percent due to the titanium metal primer layers, which are thicker than typical primer layers of the prior art. However, after high tempering processing such as bending, annealing, tempering, laminating or glass welding, the transmittance increases to 80 to 85 percent, without any color change as has been experienced with prior art coatings. In addition, the resistivity and emissivity of the coating decrease. For example, after 15 minutes at 1160°F (about 627°C) the resistivity decreases from 5.3 to 3.7 ohms per square, and the emissivity decreases from 0.09 to 0.06.

The improved durability of the coated article resulting from the improved adhesion between the metal and metal oxide films as a result of the primer layers of the present invention is readily demonstrated by a simple abrasion test consisting of wiping the coated surface with a damp cloth. A surface coated with zinc stannate-silver zinc stannate having no primer layers increases in reflectance from about 6 percent to about 18 percent after several passes of a damp cloth, indicating removal of both the top zinc stannate and the underlying silver films. In contrast, prolonged vigorous rubbing with a damp cloth produces no visible change in a zinc

stannate:titanium:silver titanium:zinc stannate coated article comprising the primer layers of the present invention.

Preferred titanium oxide protective coatings have thicknesses in the range of about 10 to 50 Angstroms. With a titanium oxide protective coating about 20 Angstroms thick, the durability of a multiple layer coating in accordance with this example is increased from 2 hours to 22 hours in a 2½ percent salt solution at ambient temperature, and from 5 hours to one week in the Cleveland humidity test conducted with a Q-Panel Cleveland Condensation Tester Model QCT-ADO containing deionized water at 150°F (about 66°C).

EXAMPLE II

A neutral multiple-layer film is deposited on a glass substrate to produce a conductive, heat resistant coated product. A stationary cathode measuring 5 by 17 inches (12.7 by 43.2 centimeters) comprises a sputtering surface of zinc. A SOLEX® tinted glass substrate is placed in the coating chamber which is evacuated to establish a pressure of 4 millitorr in an atmosphere of 50:50 argon:oxygen. The cathode is sputtered in a magnetic field at a power of 1.7 kilowatts while the gas is conveyed past the sputtering surface at a rate of 110 inches (2.8 meters) per minute. A film of zinc oxide is deposited on the glass surface. Three passes produce a film thickness resulting in a decrease in transmittance from 84 percent for the tinted glass substrate to 73.2 percent for the zinc oxide coated glass substrate. Next, a layer of silver is deposited over the zinc oxide layer by sputtering a silver cathode target in an atmosphere of argon gas at a pressure of 4 millitorr. With the substrate passing under the silver cathode target at the same rate, two passes are necessary to deposit ten micrograms of silver per square centimeter, corresponding to a film thickness of about 90 Angstroms, reducing the transmittance to 67 percent. A titanium-containing primer layer is sputtered over the silver layer, further reducing the transmittance to 61.6 percent. Finally the second antireflective layer of zinc oxide is deposited over the titanium-containing primer layer, increasing the transmittance to 81.9 percent. The silver resistance is 7.7 ohms per square, and the multiple-layer coating is visually neutral.

Preferably, the coated SOLEX® glass substrate is subsequently laminated with an additional transparent sheet, with the coating between the sheets to form a laminated transparency with a conductive heatable coating to provide deicing, defrosting and or defogging properties. Because the coating is not exposed to the elements in this embodiment, a

protective overcoat is not necessary. In other applications where a protective overcoat is desired, titanium oxide is preferred as disclosed in U.S. Serial No. 812,680 filed December 23, 1985 by Gillery et al, the disclosure of which is incorporated herein by reference.

The above examples are offered to illustrate the present invention. Various modifications of the product and the process are included. For example, other coating compositions are within the scope of the present invention. Depending on the proportions of zinc and tin when a zinc:tin alloy is sputtered, the coating may contain widely varying amounts of zinc oxide and tin oxide in addition to zinc stannate. The primer layers may comprise titanium metal in various states of oxidation. Other metals such as zirconium, chromium, zinc:tin alloy and mixtures thereof are also useful as primers in accordance with the present invention. The thicknesses of the various layers are limited primarily by the desired optical properties such as transmittance. The same neutral conductive heatable multiple-layer film may be deposited on clear glass, which may also be subsequently laminated, preferably to a tinted substrate, such as SOLEX® glass. Process parameters such as pressure and concentration of gases may be varied over a broad range. Protective coatings of other chemically resistant materials may be deposited in either metal or oxide states. The scope of the present invention is defined by the following claims.

Claims

1. A high transmittance, low emissivity heatable article comprising:
 - a. a transparent nonmetallic substrate;
 - b. a first transparent anti-reflective metal oxide film comprising zinc deposited on a surface of said substrate;
 - c. a transparent infrared reflective metallic film deposited on said antireflective metal oxide layer;
 - d. a metal-containing primer layer deposited on said infrared reflective metallic film, wherein said metal is selected from the group consisting of titanium, zirconium, chromium, zinc:tin alloy and mixtures thereof; and
 - e. a second transparent anti-reflective metal oxide film comprising zinc deposited on said metal-containing primer film.
2. An article according to claim 1, wherein the substrate is glass.
3. An article according to claim 2, wherein the reflective metallic film is silver.

4. An article according to claim 3, wherein the metal oxide comprises an oxide reaction product of an alloy comprising zinc and tin.

5. An article according to claim 1 wherein said primer film comprises titanium.

6. An article according to claim 1, further comprising an additional primer layer between said first transparent anti-reflective film and said transparent infrared reflective metallic film.

7. An article according to claim 1, further comprising a protective metal-containing overcoat deposited over said second anti-reflective metal oxide film.

8. A method for depositing high-temperature resistant film comprising the steps of:

a. sputtering a metal cathode target comprising zinc in a reactive atmosphere comprising oxygen thereby depositing a first metal oxide film comprising zinc on a surface of a substrate;

b. sputtering a reflective metallic film over said metal oxide layer;

c. sputtering a metal-containing primer layer over said reflective metallic film wherein said metal is selected from the group consisting of titanium, zirconium, chromium, zinc-tin alloy and mixtures thereof; and

d. sputtering a second metal oxide film comprising zinc over said primer layer.

9. A method according to claim 8, wherein said metal oxide film comprises an oxide reaction product of an alloy comprising zinc and tin.

10. A method for making a multiple layer low emissivity coated product comprising the steps of:

a. placing a transparent, nonmetallic substrate in a sputtering chamber;

b. sputtering a cathode target comprising an alloy of zinc and tin in a reactive atmosphere comprising oxygen to deposit a first transparent metal alloy oxide film on a surface of said substrate;

c. sputtering a titanium target to deposit a primer layer on said oxide film;

d. sputtering a silver cathode target in an inert atmosphere to deposit a transparent silver film on said primer layer;

e. sputtering a titanium target to deposit a second primer layer on said silver film; and

f. sputtering a cathode target comprising an alloy of zinc and tin in a reactive atmosphere comprising oxygen to deposit a second metal alloy oxide film on said second primer layer.

11. A method according to claim 8 or 10 comprising the further step of subjecting the multiple-layer coated article to high temperature processing whereby the transmittance of the coating increases.

12. A method according to claim 11, wherein said high temperature processing the step of laminating said coated article to a second transparent

sheet, with the coating therebetween, to form a neutral conductive heatable laminated transparency.

13. The method according to claim 8 or 10, wherein the substrate is glass.

14. The method according to claims 8 or 10, further comprising the step of depositing a metal-containing protective coating over said second metal alloy oxide film.

15. The method according to claims 8 or 10, wherein said primer layers comprise titanium.



European Patent
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EUROPEAN SEARCH REPORT ..

Application Number

EP 87 11 8457

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl. 4)
Y,D	EP-A-0 183 052 (PPG INDUSTRIES, INC.) * Claims 2-5 *	1-15	C 03 C 17/36
Y	EP-A-0 035 906 (TEIJIN LTD) * Claims *	1-15	
P,Y D	EP-A-0 226 993 (PPG INDUSTRIES, INC.) * Claims *	1-15	
			TECHNICAL FIELDS SEARCHED (Int. Cl. 4)
			C 03 C G 02 B
The present search report has been drawn up for all claims			
Place of search THE HAGUE		Date of completion of the search 07-04-1988	Examiner BOUTRUCHE J. P. E.
CATEGORY OF CITED DOCUMENTS			
X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document		T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document	

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